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FORM PTO 1449 (modified)

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICERADEMA

LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary)

May 3, 2005

ATTY DOCKET NO. 00684.003654

APPLICATION NO. 10/529,891

APPLICANT Takako YAMAGUCHI et al.

FILING DATE April 1, 2005

GROUP Unassigned

May 3, 2005			FILING DATE April 1, 2005		GROUP Unassigned	
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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